

|    | Type | L # | Hits   | Search Text   | DBs  | Time Stamp          |
|----|------|-----|--------|---|--|---------------------|
| 2  | BRS  | L7  | 58617  | (nitrogen or nitrogen-contain\$4 or N2-contain\$4 or nitridat\$5 or nitrifying or nitrified or nitridiz\$4 or N?su\$3) same (thickness or angstrom or nm or nanometer or nano-meter or nanometre) | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TD<br>B | 2002/10/25<br>16:14 |
| 3  | BRS  | L14 | 185355 | (SiO2 or SiO?sub\$2 or oxide or dioxide or oxidat\$4 or oxidiz\$5) same (thickness or angstrom or nm or nanometer or nano-meter or nanometre)   | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TD<br>B | 2002/10/25<br>16:18 |
| 4  | BRS  | L21 | 16071  | (nitrogen or N-atom or N-ion or nitrogen-atom or nitrogen-ion) near20 (dispers\$4 or diffus\$4)   | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TD<br>B | 2002/10/25<br>16:19 |
| 5  | BRS  | L28 | 1537   | 7 and 14 and 21   | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TD<br>B | 2002/10/25<br>16:17 |
| 11 | BRS  | L70 | 2158   | (nitrogen or N-atom or N-ion or nitrogen-atom or nitrogen-ion) near20 (dispers\$4 or diffus\$4) near20 (oxide or dioxide or SiO2 or SiO?su\$3 or oxide-region)                                    | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TD<br>B | 2002/10/25<br>16:22 |

|    | Type | L # | Hits | Search Text                       | DBs  | Time Stamp          |
|----|------|-----|------|-----------------------------------|--|---------------------|
| 12 | BRS  | L77 | 319  | 7 and 14 and 70 and semiconductor | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TD<br>B | 2002/10/25<br>16:22 |

|   | Type | L # | Hits   | Search Text   | DBs  | Time Stamp          |
|---|------|-----|--------|---|--|---------------------|
| 1 | BRS  | L1  | 59411  | (nitrogen or nitrogen-contain\$4 or N2-contain\$4 or nitridat\$5 or nitrifying or nitrified or nitridiz\$4 or N?su?\$3) same (thickness or angstrom or nm or nanometer or nano-meter)   | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TDB | 2002/10/25<br>12:21 |
| 2 | BRS  | L8  | 185263 | (SiO2 or SiO?sub\$2 or oxide or dioxide or oxidat\$4 or oxidiz\$5) same (thickness or angstrom or nm or nanometer or nano-meter)  | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TDB | 2002/10/25<br>12:16 |
| 3 | BRS  | L15 | 18689  | 1 and 8 and semiconductor   | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TDB | 2002/10/25<br>12:10 |
| 4 | BRS  | L22 | 21320  | (nitrogen or nitrogen-contain\$4 or N2-contain\$4 or nitridat\$5 or nitrifying or nitrified or nitridiz\$4 or N?su?\$3) near20 (thickness or angstrom or nm or nanometer or nano-meter) | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TDB | 2002/10/25<br>12:13 |
| 5 | BRS  | L29 | 106276 | (SiO2 or SiO?sub\$2 or oxide or dioxide or oxidat\$4 or oxidiz\$5) near20 (thickness or angstrom or nm or nanometer or nano-meter)  | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TDB | 2002/10/25<br>12:15 |

|   | Type | L # | Hits | Search Text  | DBs  | Time Stamp          |
|---|------|-----|------|--|--|---------------------|
| 6 | BRS  | L36 | 6727 | 22 and 29 and (semiconductor or semiconductor-device)  | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TD<br>B | 2002/10/25<br>12:16 |
| 7 | BRS  | L43 | 5683 | 36 and (grow\$4 or oxidat\$4 or oxidiz\$5)   | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TD<br>B | 2002/10/25<br>12:17 |
| 8 | BRS  | L50 | 4892 | 36 and ((grow\$4 or oxidat\$4 or oxidiz\$5) same (SiO2 or SiO?sub\$2 or oxide or dioxide))   | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TD<br>B | 2002/10/25<br>12:20 |
| 9 | BRS  | L57 | 2802 | 36 and ((grow\$4 or oxidat\$4 or oxidiz\$5) same (SiO2 or SiO?sub\$2 or oxide or dioxide) same (nitride or nitrogen or nitrogen-contain\$4 or nitridat\$5 or nitridiz\$4 or nitrifying)) | USPAT;<br>US-PG<br>PUB;<br>EPO;<br>JPO;<br>DERW<br>ENT;<br>IBM_TD<br>B | 2002/10/25<br>12:22 |